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INFORMATION DISCLOSURE STATEMENT BY APPLICANT (use as many sheets as necessary)				Application Number	10 / 713,074
				Filing Date	11/1/03
				First Named Inventor	Kia Silverbrook
				Art Unit	2853
				Examiner Name	AN H. DO
				Attorney Docket Number	ZG147US
Sheet	1	of	1		

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Examiner Signature		Date Considered	3/25/04
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